編號:

208

國立成功大學九十七學年度碩士班招生考試試題

系所: 電機工程學系在職專班甲組

科目: 半導體概論(專班)

本試顯是否可以使用計算機: ☑可使用 , □不可使用

(請命題老師勾選)

考試日期:0301, 節次:3

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- 1. (25%) An abrupt Si p-n junction has an acceptor concentration $N_a = 10^{17} \, cm^{-3}$ on the p-side and a donor concentration $N_d = 10^{16} cm^{-3}$ on the n-side at 300K. (a) Please find the contact potential, and (b) draw an equilibrium band diagram which shows the exact position of Fermi level in each side. (Give the Boltzmann's constant $k = 1.38 \times 10^{-23} J/K$, band gap of Si $E_{\nu} = 1.2 eV$, and the intrinsic carrier concentration of Si $n_i = 1.5 \times 10^{10} cm^{-3}$.)
- 2. (25%) Phosphorus is diffused into a thick slice of silicon with no previous phosphorus in it at a temperature of 1100°C. If the surface concentration of the phosphorus is 1×10^{18} atoms/cm³ and its concentration at 1 µm is 1×10^{15} atoms/cm³. How long does the diffusion process take? Diffusion coefficient equals 3.0 × 10⁻¹⁷ m²/s for P diffusing in Si at 1100°C. (Hint: the solution of the time-dependent diffusion equation is an error function. The error function table given below might be used.)

erf (z)	z
0.9981	2.2
0.993	2.4

- 3. (20%) Please sketch npn bipolar transistor's minority carrier distribution under forward active and inverse active mode in each regions. Please also indicate space charge regions and thermal equilibrium minority carrier concentration levels on your graph.
- 4. (15%) What semiconductor material's properties can be measured by the Hall effect and briefly describe Hall effect measurements.
- 5. (15%) Please sketch the energy band diagram of an nN heterojunction in thermal equilibrium. Indicate conduction, valence band and Fermi level on your sketch.